AMENDMENTS TO THE CLAIMS

- 1. (Cancelled)
- 2. (Currently amended) An electrodeposited film wherein <u>a member selected from</u> the group consisting of (a) a simple-silver layer, (b) an alloy layer of silver and antimony, (c) an alloy layer of copper and tin or zinc, (d) a ternary alloy layer of copper, tin and zinc, (e) a simple-zinc layer and, or (f) an alloy layer of zinc and copper is applied to form an under layer, and <u>a member selected from the group consisting of (g)</u> a simple-tin layer, (h) an alloy layer of tin and copper and/or silver, (i) <u>a simple-an</u> indium layer and, or (j) an alloy layer of indium and silver is applied to form an upper layer.
- 3. (Currently amended) The electrodeposited film according to Claim 1 or 2, wherein the upper layer is (h) an alloy layer of tin and copper and/or silver, and the amount of tin contained in the upper layer is 90 to less than 100 weight % of the upper layer when the upper layer is (h) an alloy layer of tin and copper and/or silver.
- 4. (Currently amended) The electrodeposited film according to Claim 1-or-2, wherein the upper layer is (j) an alloy layer of indium and silver, and the amount of indium contained in the upper layer is 60 to less than 100 weight % of the upper layer when the upper layer is (j) an alloy layer of indium and silver.
- 5. (Currently amended) The electrodeposited film according to Claim 1-or-2, wherein the under layer is (b) an alloy layer of silver and antimony, and the amount of silver contained in the under layer is 90 to less than 100 weight % of the under layer when the under layer is (b) an alloy layer of silver and antimony.
- 6. (Currently amended) The electrodeposited film according to Claim 1 or 2, wherein the under layer is (c) an alloy layer of copper and zinc, or (d) a ternary alloy layer of copper, tin and zinc, and the amount of copper contained in the under layer is 50

to 99 weight % of the under layer-when the under layer is (c) an alloy layer of copper and tin or zinc, or (d) a ternary alloy layer of copper, tin and zinc.

- 7. (Currently amended) The electrodeposited film according to Claim 1 or 2, wherein the under layer is (f) an alloy layer of zinc and copper, and the amount of zinc contained in the under layer is 60 to less than 100 weight % of the under layer when the under layer is (f) an alloy layer of zinc and copper.
- 8. (Currently Amended) The electrodeposited film according to Claim 1 or 2, wherein the under layer has a thickness of 1 to 1,000 μ m and the upper layer has a thickness of 1 to 200 μ m.

9-10. (Cancelled)

- 11. (Currently amended) <u>Sliding Parts A sliding part</u> wherein the <u>a</u> surface of a base material is coated with the electrodeposited film according to Claim 2.
- 12. (Currently amended) The sliding parts part according to Claim 11, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and or ceramicsceramic.
- 13. (Currently amended) <u>Sliding Parts A sliding part</u> wherein the <u>a</u> surface of a base material is coated with the electrodeposited film according to Claim 3.
- 14. (Currently amended) The sliding parts-part according to Claim 13, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and or eeramicsceramic.

- 15. (Currently amended) Sliding Parts A sliding part wherein the a surface of a base material is coated with the electrodeposited film according to Claim 4.
- 16. (Currently amended) The sliding parts part according to Claim 15, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and or eeramicsceramic.
- 17. (Currently amended) <u>Sliding Parts A sliding part</u> wherein the <u>a</u> surface of a base material is coated with the electrodeposited film according to Claim 5.
- 18. (Currently amended) The sliding parts part according to Claim 17, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and of ceramics ceramic.
- 19. (Currently amended) Sliding Parts A sliding part wherein the a surface of a base material is coated with the electrodeposited film according to Claim 6.
- 20. (Currently amended) The sliding parts-part according to Claim 19, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and or ceramicsceramic.
- 21. (New) An electrodeposited film wherein (c)' an alloy layer of copper and tin is applied to form an under layer, and (h)' an alloy layer of tin and copper is applied to form an upper layer.
- 22. (New) The electrodeposited film according to Claim 21, wherein the amount of tin contained in the upper layer is 90 to less than 100 weight % of the upper layer.

- 23. (New) The electrodeposited film according to Claim 21, wherein the amount of copper contained in the under layer is 50 to 99 weight % of the under layer.
- 24. (New) The electrodeposited film according to Claim 21, wherein the under layer has a thickness of 1 to 1,000 μ m and the upper layer has a thickness of 1 to 200 μ m.
- 25. (New) A sliding part wherein a surface of a base material is coated with the electrodeposited film according to Claim 21.
- 26. (New) The sliding part according to Claim 25, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and ceramic.
- 27. (New) A sliding part wherein a surface of a base material is coated with the electrodeposited film according to Claim 22.
- 28. (New) The sliding part according to Claim 27, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and ceramic.
- 29. (New) A sliding part wherein a surface of a base material is coated with the electrodeposited film according to Claim 23.
- 30. (New) The sliding part according to Claim 29, wherein the base material is a member selected from the group consisting of steel, stainless steel, aluminum, aluminum alloy, titanium, titanium alloy, copper, copper alloy and ceramic.